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PATENT  
Customer No. 23494  
Attorney Docket No. T1-31138

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

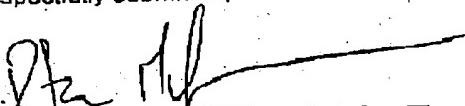
In re Application of:  
Antonio L. P. Rotondaro  
Application No.: 10/001,483  
Filed: November 1, 2001  
For: METHOD TO IMPROVE THE  
UNIFORMITY AND REDUCE THE  
SURFACE ROUGHNESS OF THE  
SILICON DIELECTRIC  
INTERFACE  
Assistant Commissioner for Patents  
Washington, DC 20231

Sir:

**POWER OF ATTORNEY**

Please grant Jonathan A. Hack, Reg. No. 47,623, power of attorney and allow  
him to be an attorney of record for the above referenced application.

Respectfully submitted,

By:   
Peter K. McLarty  
Reg. No. 44,923

Dated: May 11, 2004

TOTAL P.02

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To: Examiner M. Estrada  
From: Jonathan A. Hack  
Art Unit 2823  
Fax: 703.872.9306  
Phone: 572.272.1858  
Re: U.S. Application No.: 10/001,483  
CC:  
Attorney Docket No.: TI-31133

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